

DERWENT- 2003-883257

ACC-NO:

DERWENT- 200382

WEEK:

COPYRIGHT 2007 DERWENT INFORMATION LTD

TITLE: Sewing method of thick material e.g. wadded cloth used as trim cover, makes waste stitch closer to edge and lock stitch on inner side of the waste stitch

PRIORITY-DATA: 2002JP-0027684 (February 5, 2002)

PATENT-FAMILY:

| PUB-NO | PUB-DATE | LANGUAGE | PAGES | MAIN-IPC |
|---------------|-------------------|----------|-------|-------------|
| JP 2003225486 | A August 12, 2003 | N/A | 005 | D05B 035/10 |

INT-CL (IPC): D05B035/10

ABSTRACTED-PUB-NO: JP2003225486A

BASIC-ABSTRACT:

NOVELTY - A waste stitch (21) with a narrow sewing margin (B) is made by machine sewing of overlapped cloths (X,Y). A lock stitch (22) is formed along the inner side of waste stitch with a wider sewing margin (A).

USE - For wadded thick cloth used as trim cover.

ADVANTAGE - Enables reducing sewing margin, hence better fitting of trim cover after sewing is enabled, as the double seam compresses the evaded cloth.

DESCRIPTION OF DRAWING(S) - The figure is a sectional view of the sewn thick cloth.

waste stitch 21

lock stitch 22

wider sewing margin A

narrow sewing margin B

thick cloth to be sewn X,Y